

# Integrated Microfluidic Devices Based on Low-Temperature Co-Fired Ceramic (LTCC) Technology

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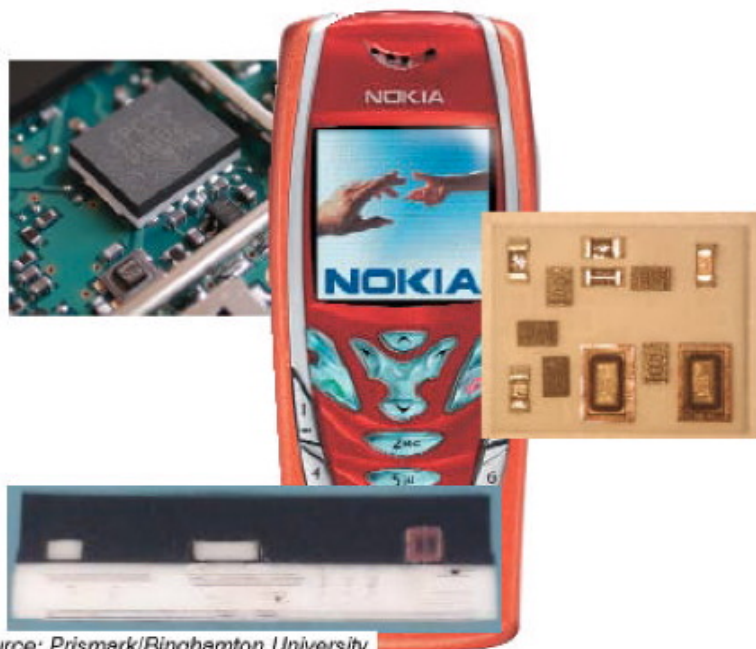
## What is LTCC?

- LTCC stands for « Low-Temperature Co-fired Ceramic ».
- The ceramic is a silicate material +  $\text{Al}_2\text{O}_3$  with outstanding chemical and thermal stability.

## How is it made?

- LTCC comes as unfired « green » sheet (tape) of various thicknesses (ceramic powder with polymer binder).
- Each sheet is shaped & screen-printed.
- Finally, the sheets are pressed & fired together.

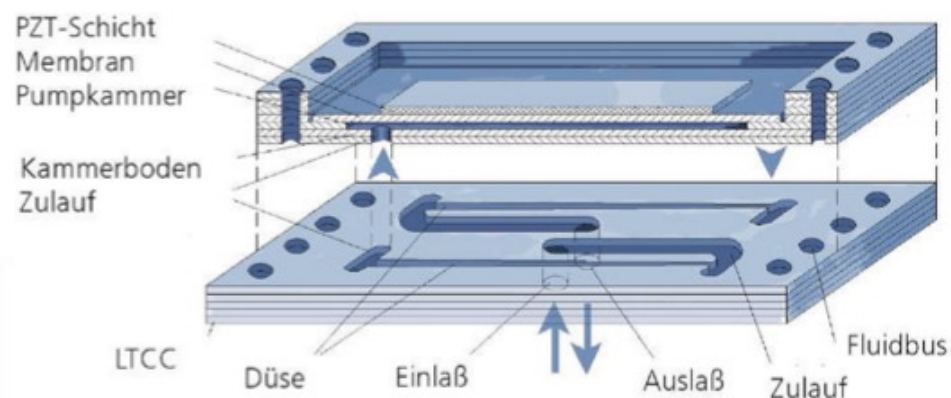
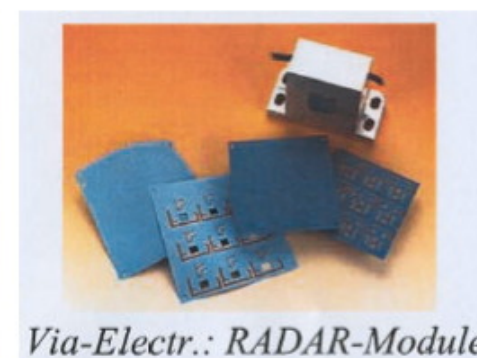
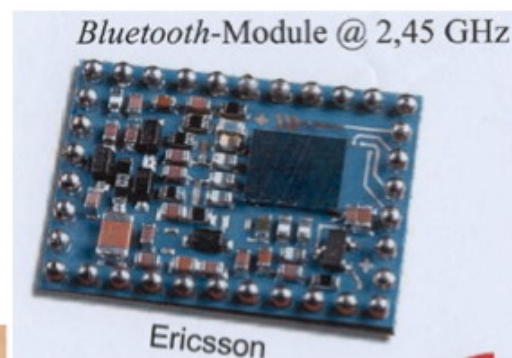
# Application examples



Source: Prismark|Binghamton University

## EPCOS FRONT END MODULE

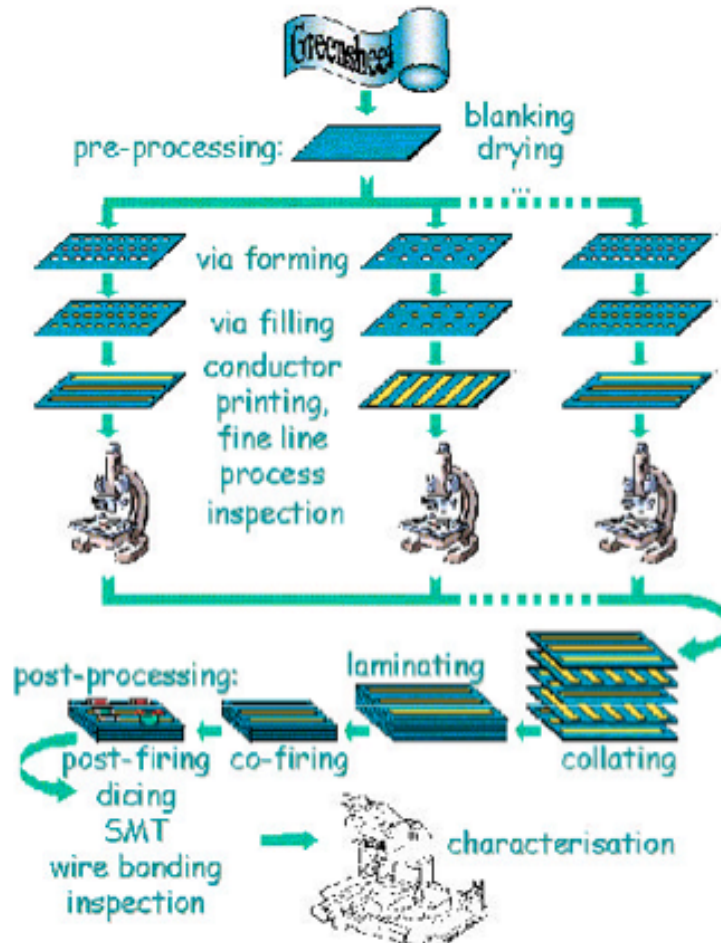
- Key component in new Nokia mobile phone architecture
- Integrates diplexer, switching, LC and SAW filters
- Analysis of LTCC integrates passives and SAW filter packages



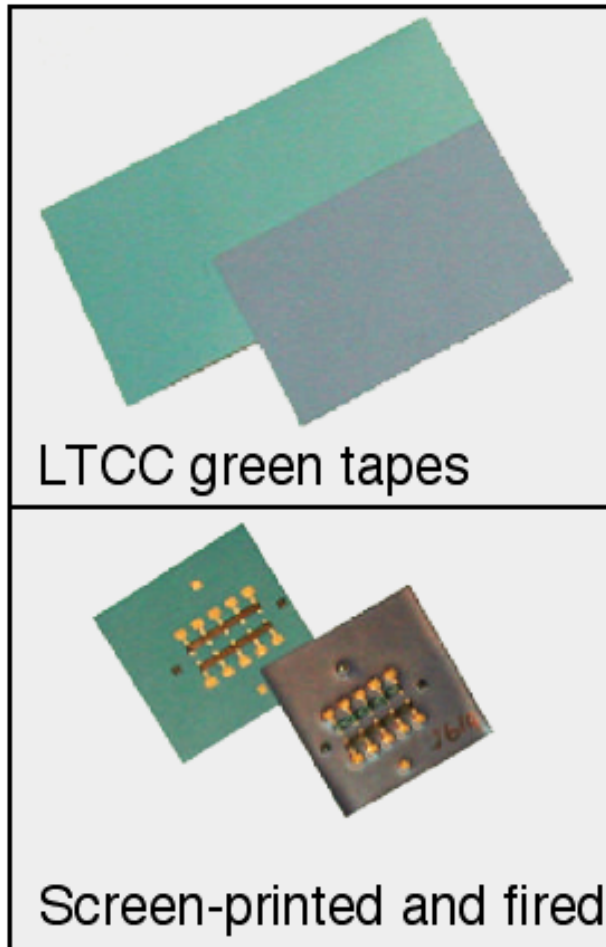
# LTCC materials system

	COMPONENTS		
	SUBSTRATE	PASSIVES	
<b>Components</b>	<b>Tape</b>	<b>Conductor</b>	<b>Resistor</b>
<b>Function</b>	Dielectric layer	Thick-film paste	Thick-film paste
<b>Functional group</b>	Dielectric powder	Precious metal, fine size powder	Conductive oxide, fine size powder
<b>Glass</b>	<ul style="list-style-type: none"> <li>⌘ Lowers <math>T_{firing}</math></li> <li>⌘ increases dielectric strength and density</li> </ul>	<ul style="list-style-type: none"> <li>⌘ Lowers <math>T_{firing}</math></li> <li>⌘ increases adhesion to substrate and density</li> </ul>	<ul style="list-style-type: none"> <li>⌘ Lowers <math>T_{firing}</math></li> <li>⌘ increases density</li> <li>⌘ surrounds conductive powder</li> </ul>
<b>Organics</b>	Binder, solvent, dispersant for appropriate rheology		

# Processing route



Source: [www.ltcc.de](http://www.ltcc.de)



# Processing - advantages

➔  $T_{\text{firing}} < 900^{\circ}\text{C}$  ➔ permits use of low resistance electrodes

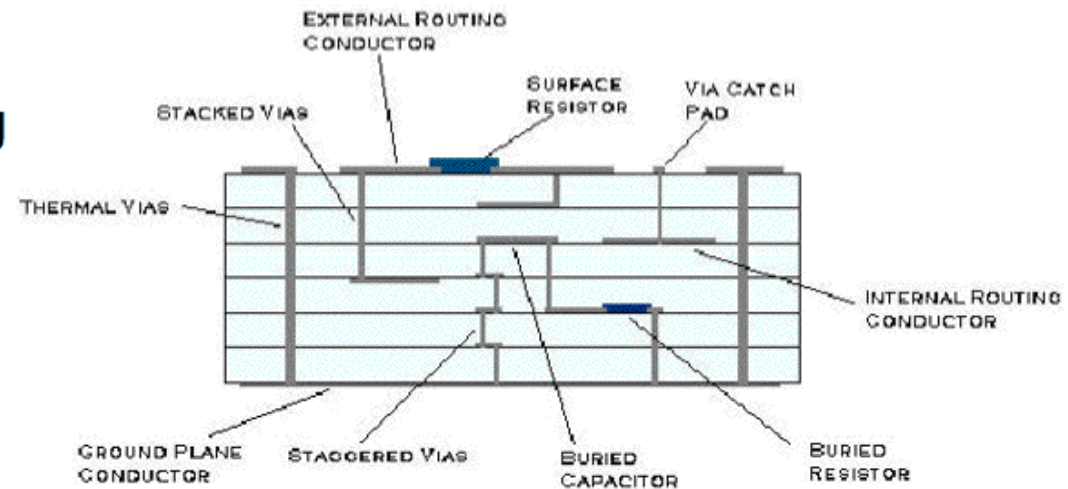
➔ High density packaging

➔ 3-D structuration

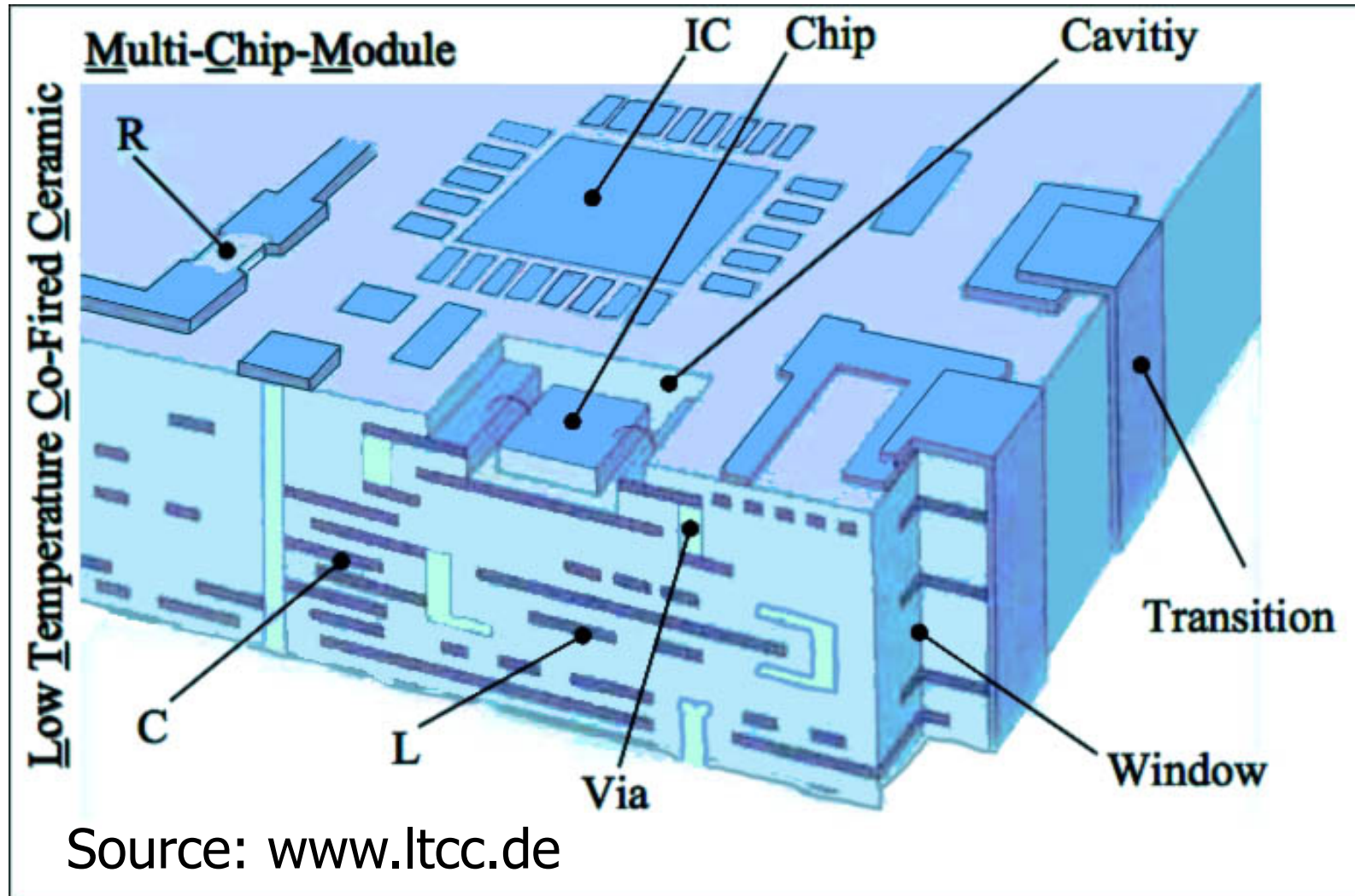
➔ Hermetic structures

➔ Reliable mechanical, thermal and electrical performance

➔ High volume – low cost fabrication possibility



# 3-D structuration of LTCC



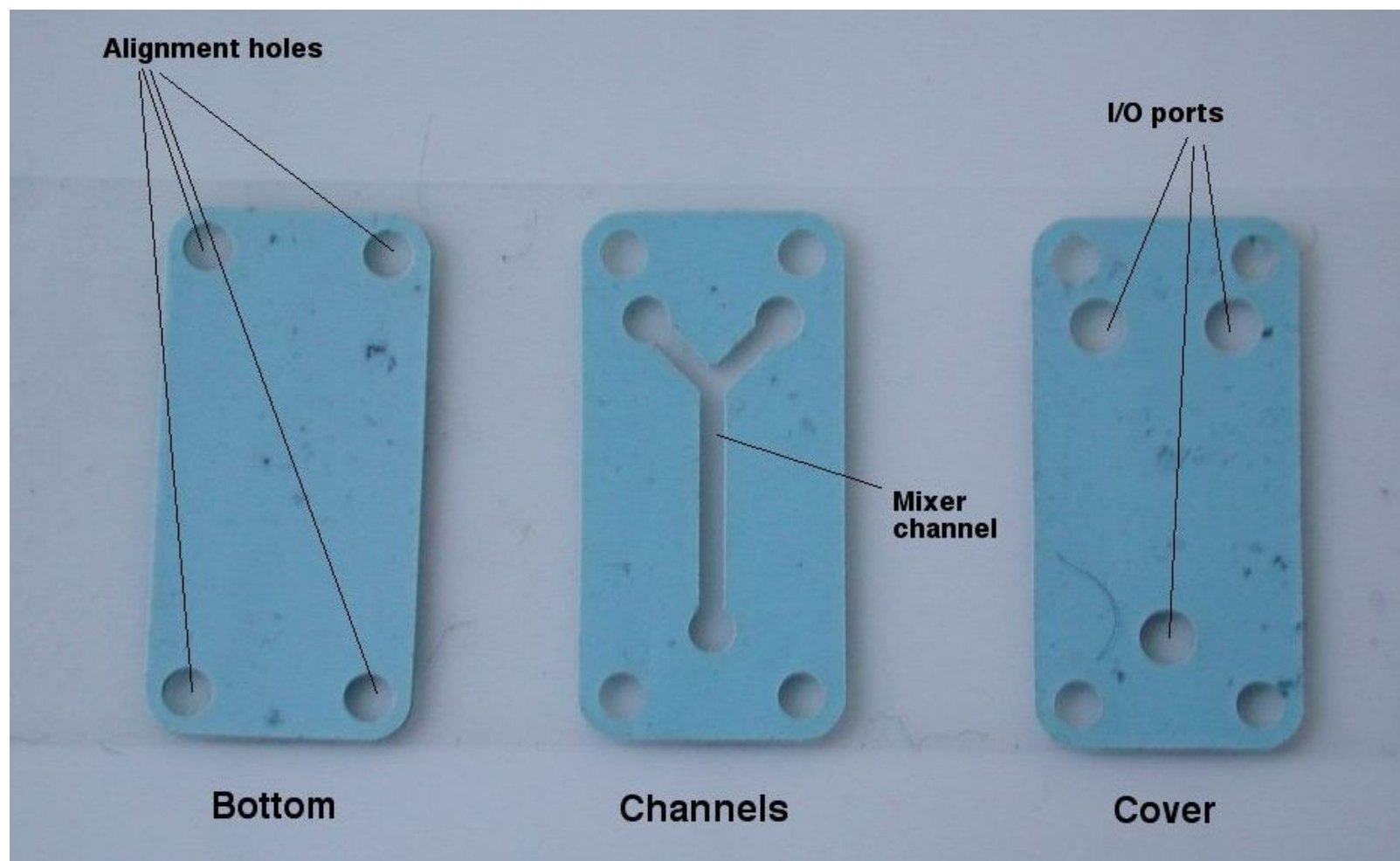
# Classical thick-film technology



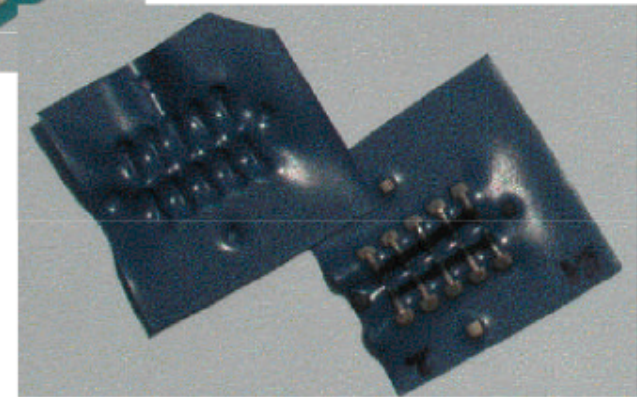
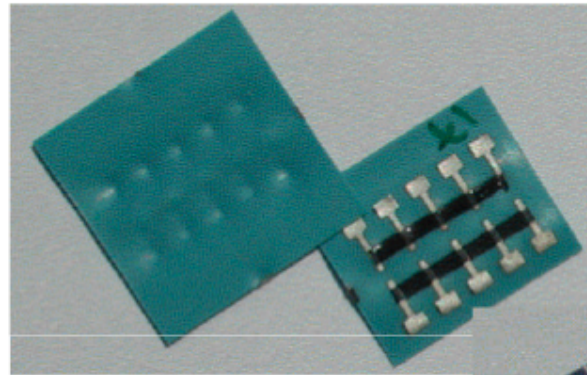
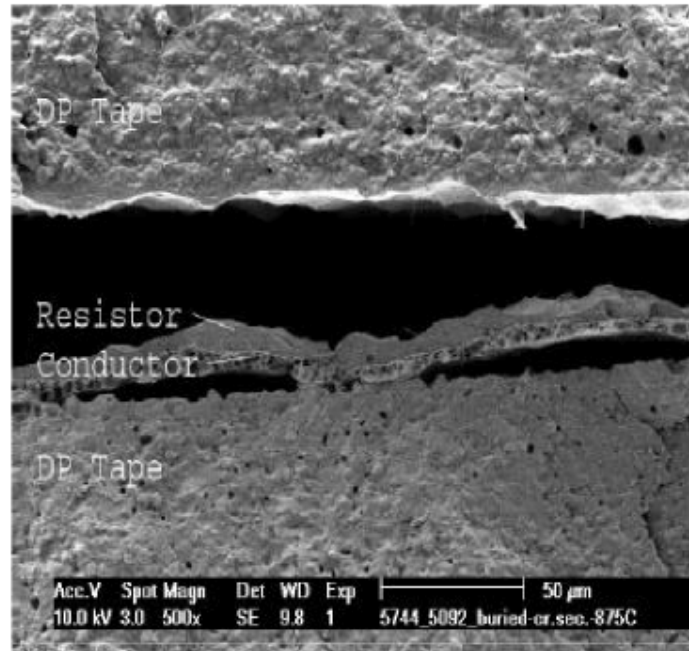
- Microreactor for calorimetric studies
- Microfluidics by classical thick-film technology
- Alumina & sealing glass (seen through glass underside)
- 3-D fluidics difficult
- Difficult to integrate new functions



# Simple structure - LTCC mixer

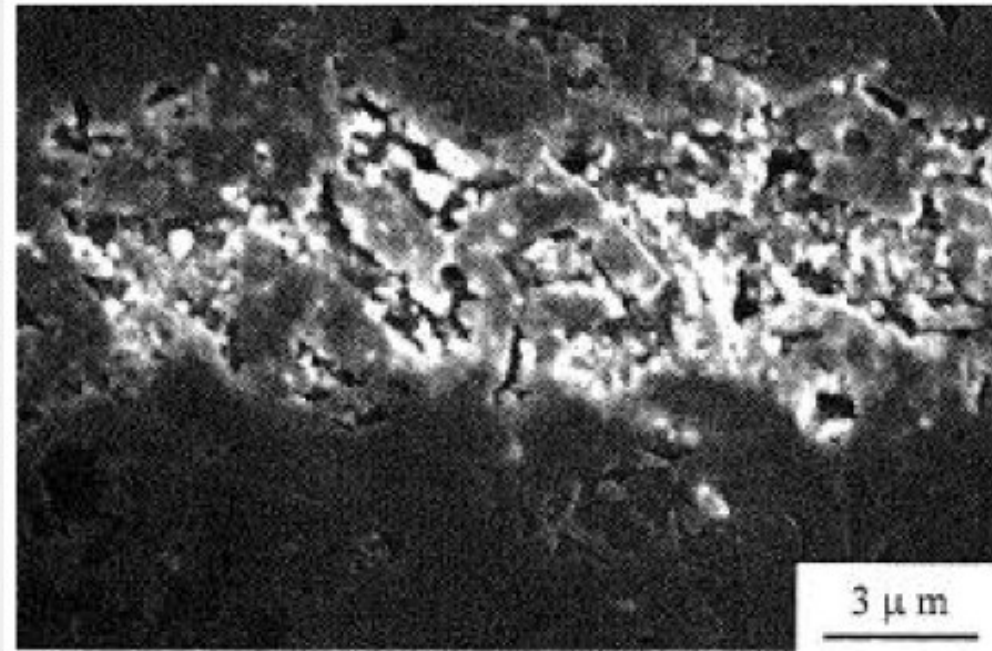
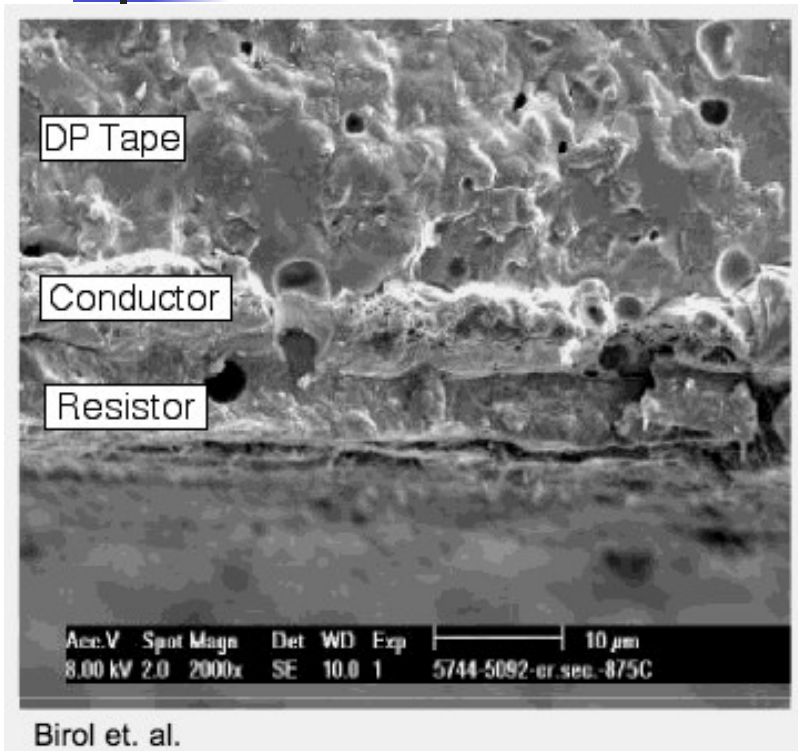


# Physical issues during firing



- Evolution of gases during debinding
- Lamination issues (thickness of layers)
- Differential sintering shrinkage

# Chemical issues during firing



- Interdiffusion of layers (esp. glass)
- Reducing / oxidising conditions

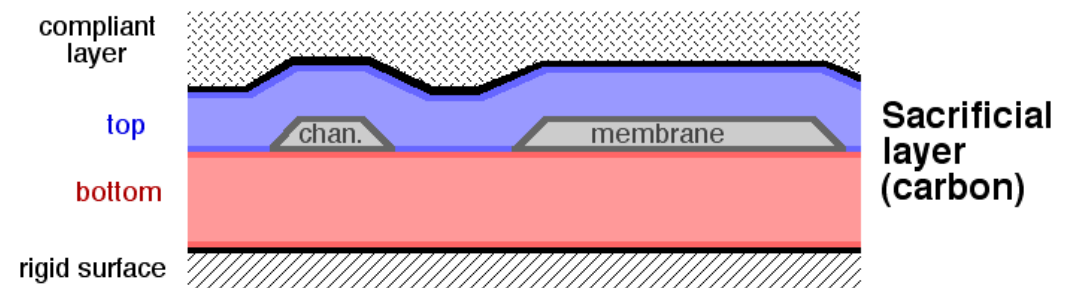
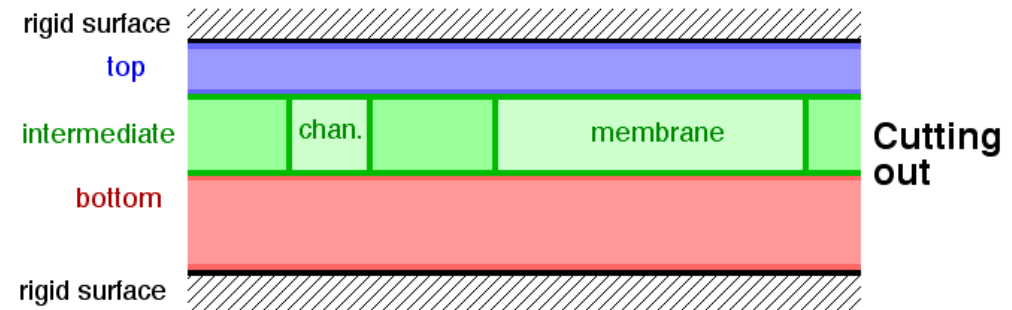
# Processing of fluidic structures

- Features

- Vias
- Channels
- Membranes
- Bridges

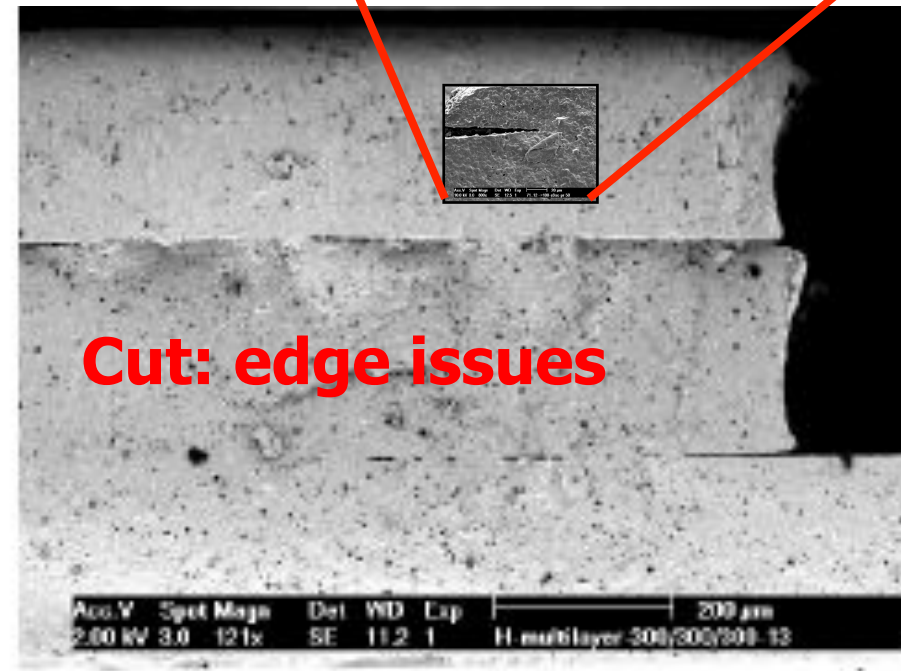
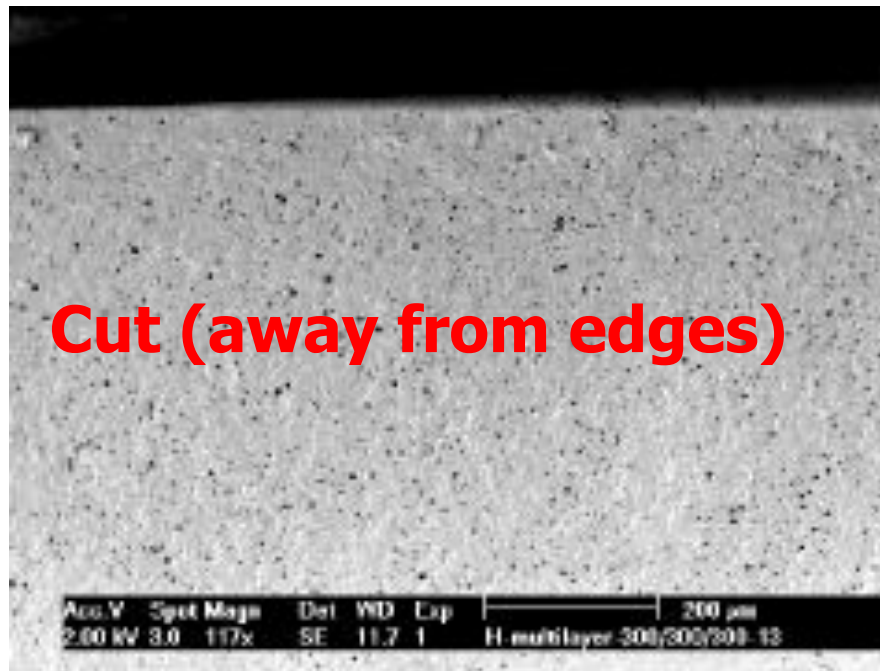
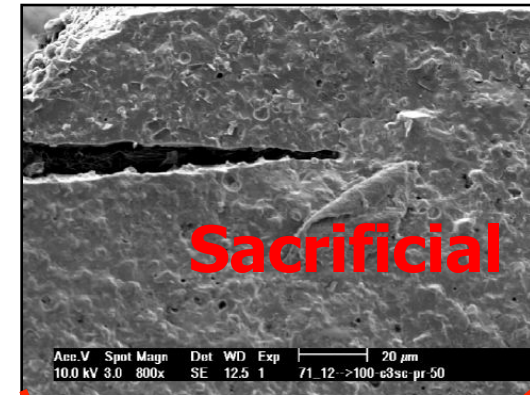
- Two techniques

- 1) Cutting out
- 2) Sacrificial layer

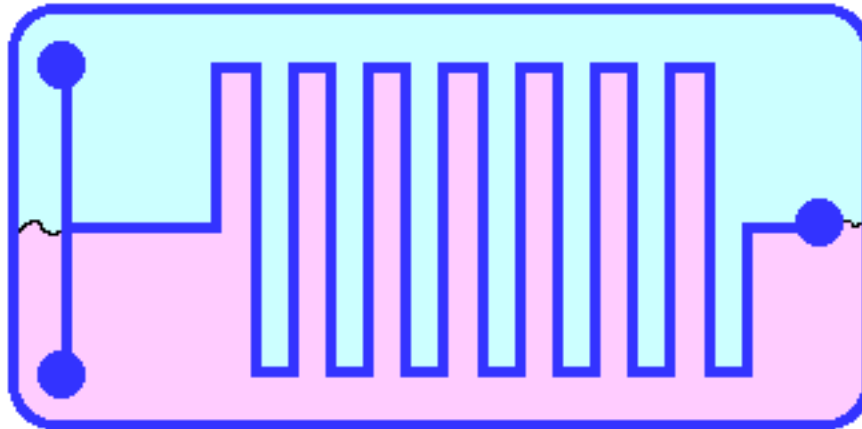


# Cutting vs. sacrificial layer

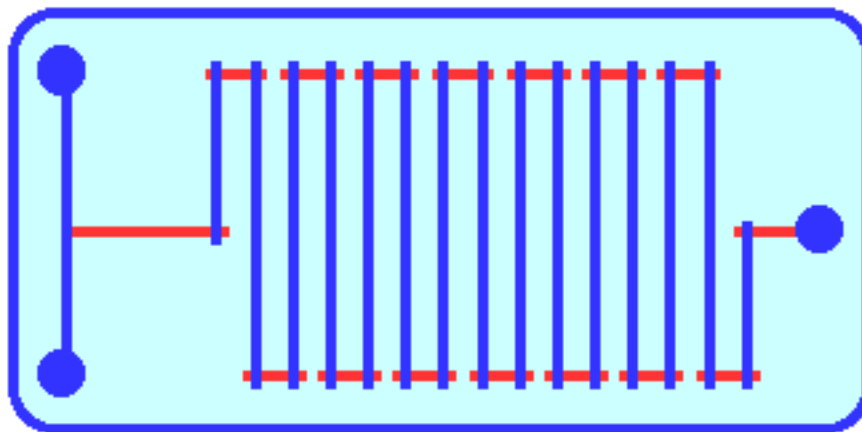
- Gap size: sacrificial max ca. 50  $\mu\text{m}$
- Complexity: cutting vs. screen-printing
- Edge quality: cut = edge issues



# Cutting: distortion of green sheet



- LTCC sheet weak
- Strong risk of clogging

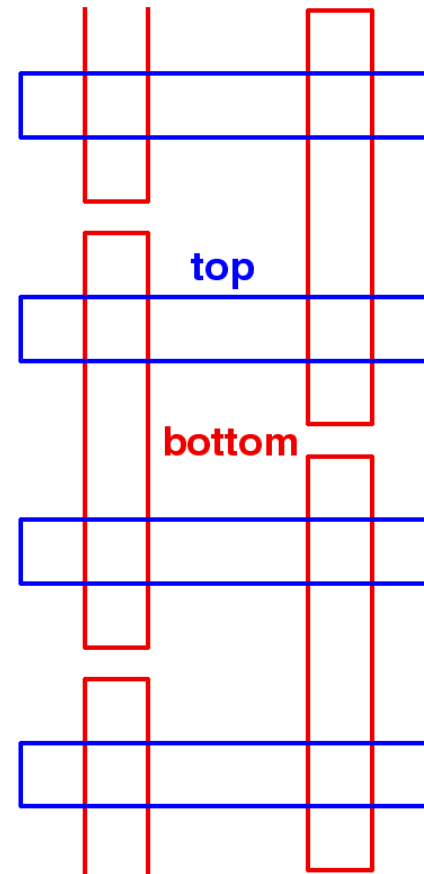
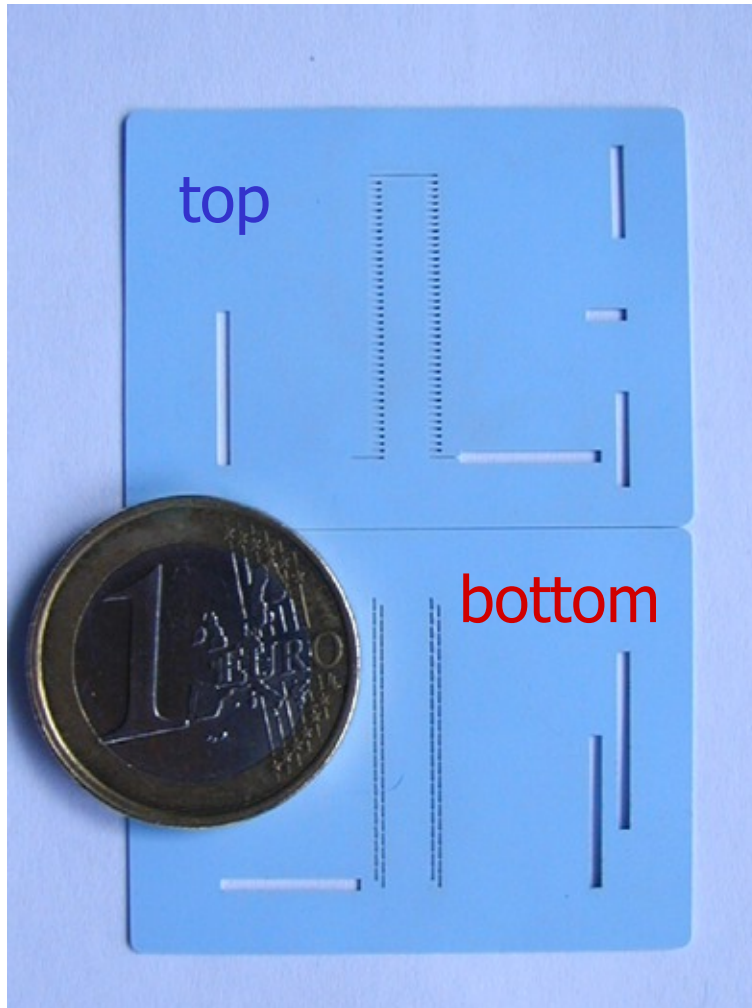


- LTCC sheet stronger
- Less risk of clogging

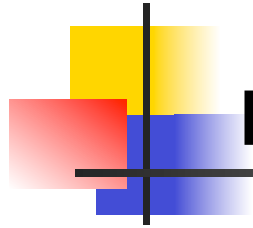
- Sheet 1 (top)
- Sheet 2 (bottom)

⇒ Avoid long, narrow & windy cuts!

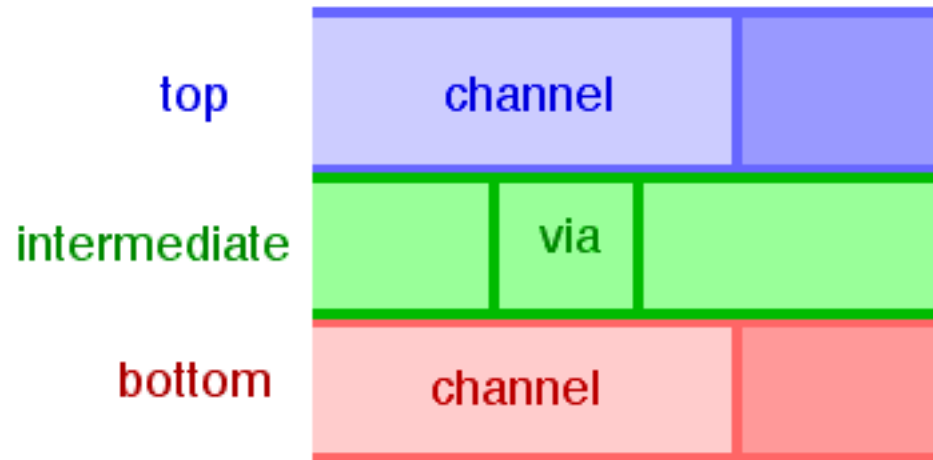
# Complex mixer by cutting



Mengeaud,  
EPFL 2002



# Making vias



« Explicit » via using  
dedicated  
intermediate layer

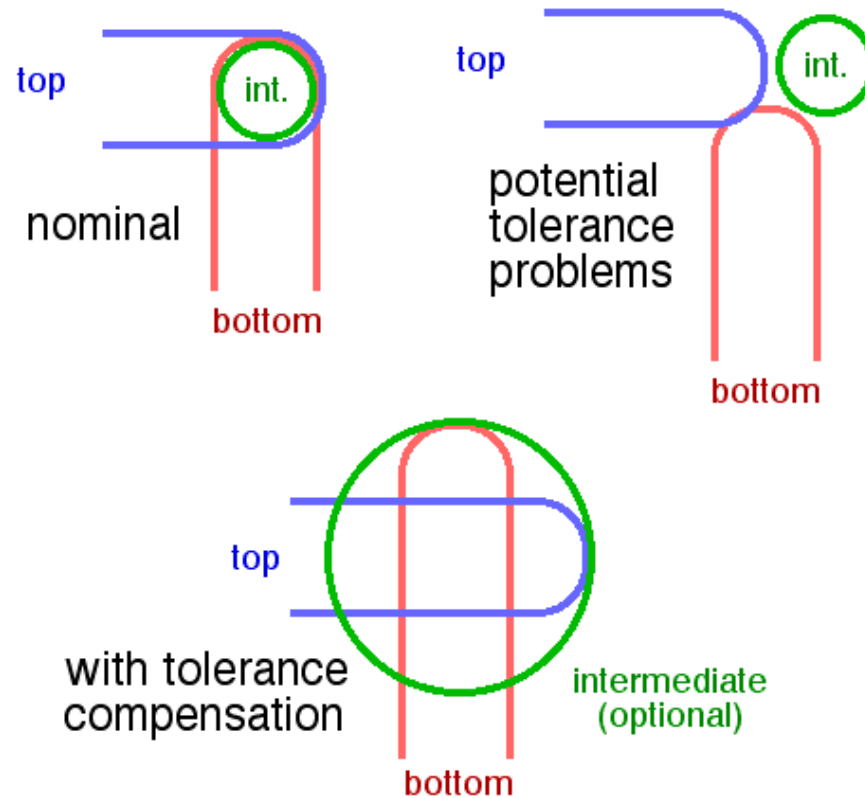


« Implicit » via  
between overlapping  
channels



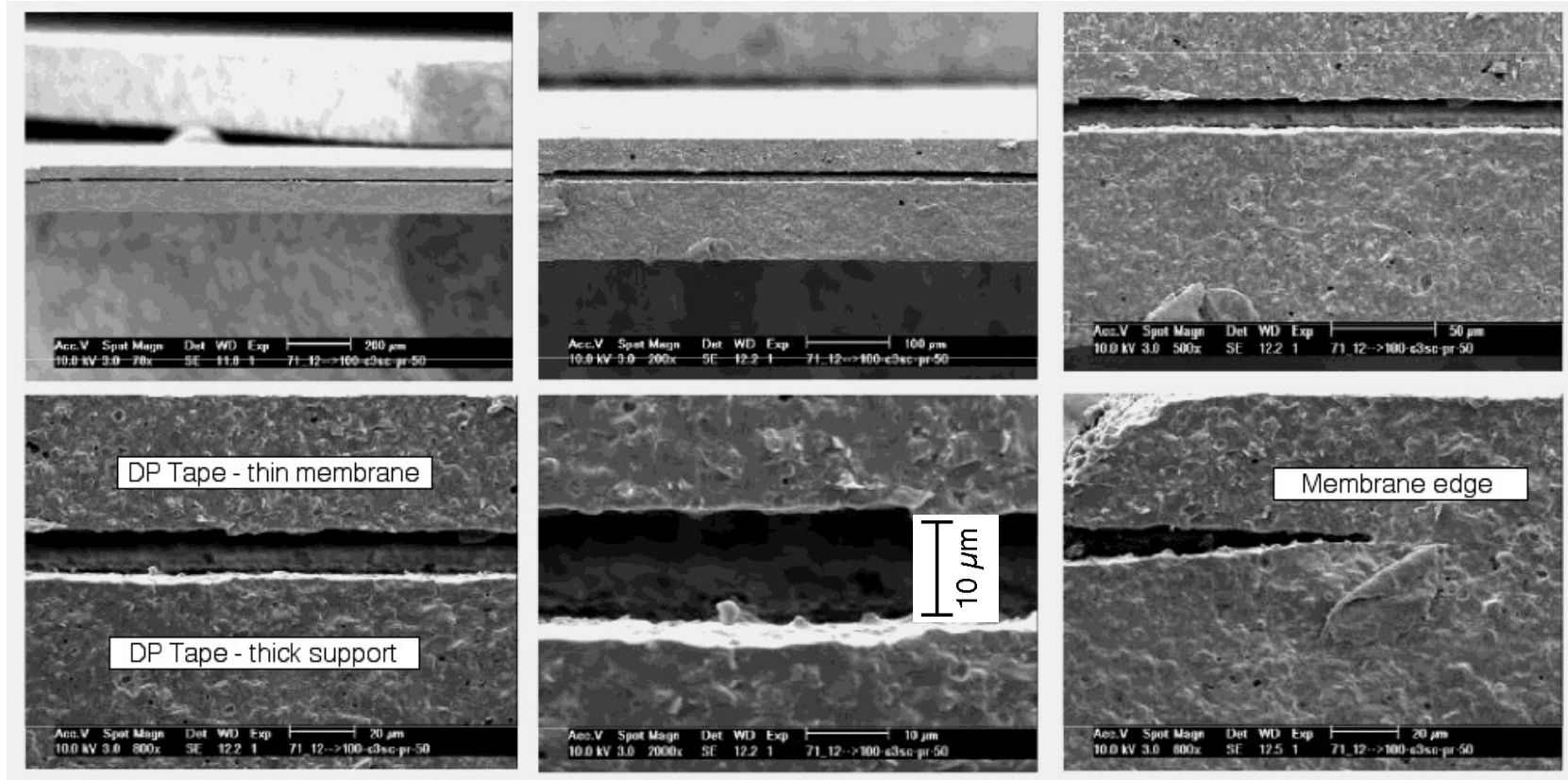


# Via alignment tolerance issues



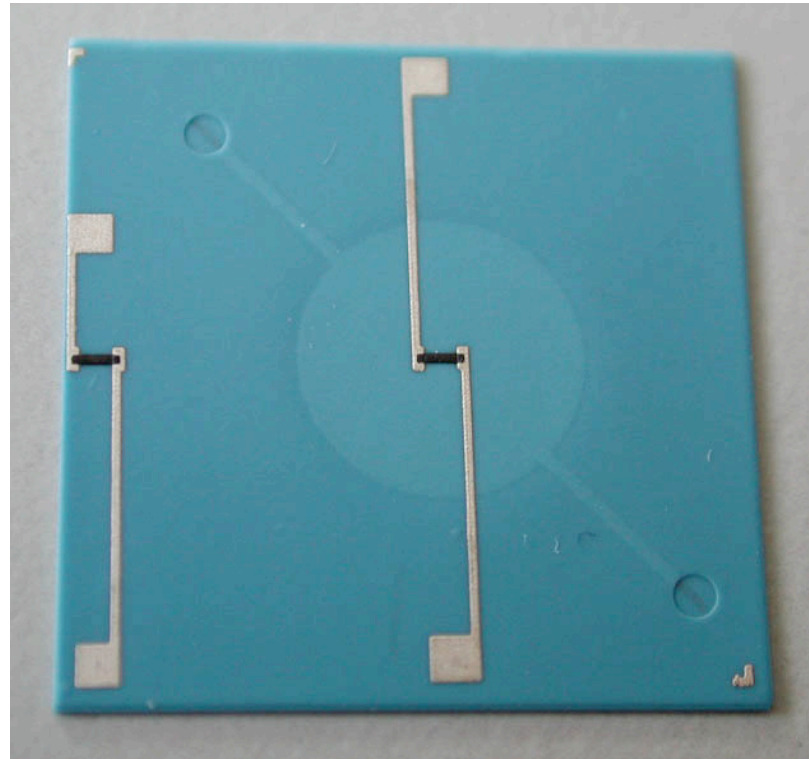
- Tolerances 50...100  $\mu\text{m}$
- Plasticity of LTCC green sheet
- Compensation needed
- Creation of parasitic dead volumes

# Membranes by sacrificial layer



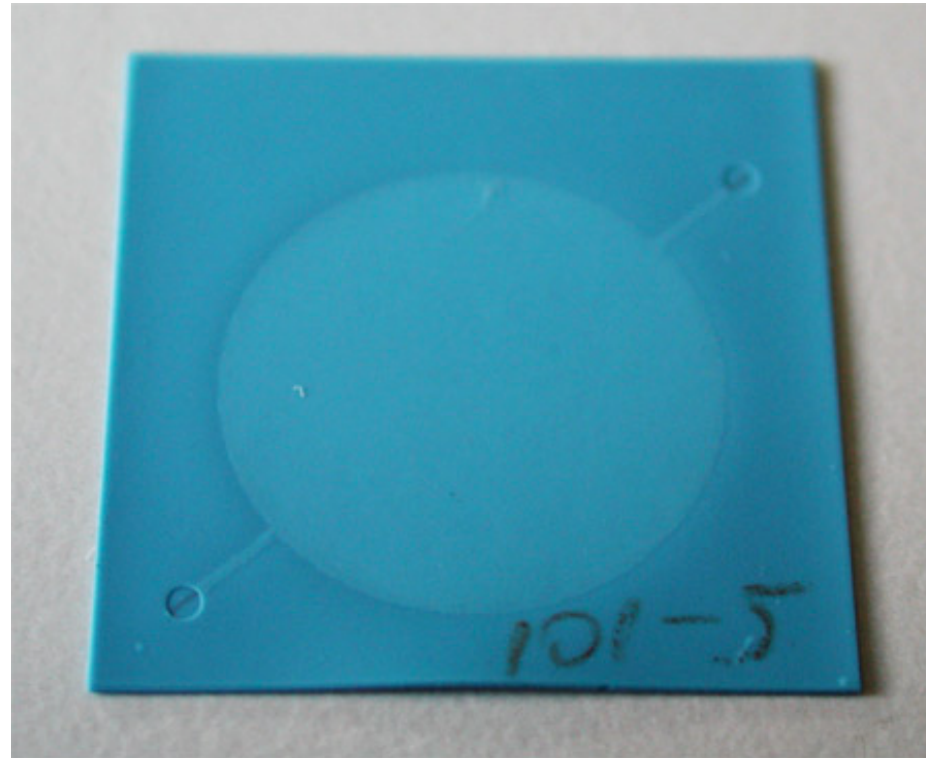
- 3-D structuration using sacrificial C layer
- 7 mm membrane, 40 μm thick, 10 μm spacing

# Membranes by sacrificial layer



- 7 mm membrane, 40  $\mu\text{m}$  thick, 15  $\mu\text{m}$  spacing
- Includes sensing & reference resistors

# Membranes by sacrificial layer



- 15 mm membrane, 40  $\mu\text{m}$  thick, 15  $\mu\text{m}$  spacing

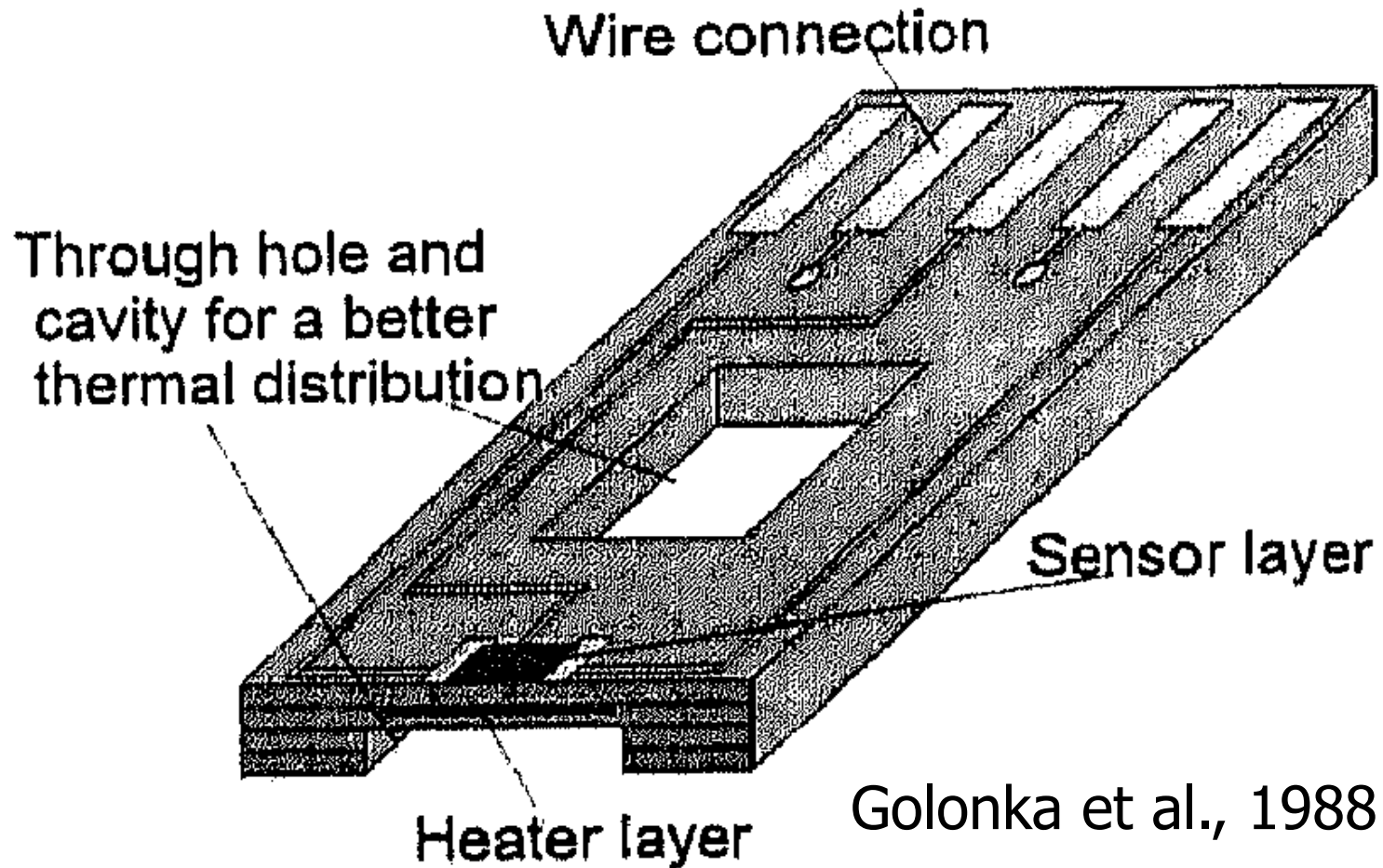
# LTCC vs. alumina

Material	LTCC	Al <sub>2</sub> O <sub>3</sub>
Available thicknesses [mm]	0.04...	0.17... 1.5
Strength [MPa]	320	600
Young's modulus [GPa]	150	320
Thermal conductivity [W/m/K]	3	25
Thermal resistance [K/W]	8300	240
Rupture strain [ppm]	2100	1900
Flexural sensitivity [N <sup>-1</sup> ·m <sup>-1</sup> ]	100	0.6

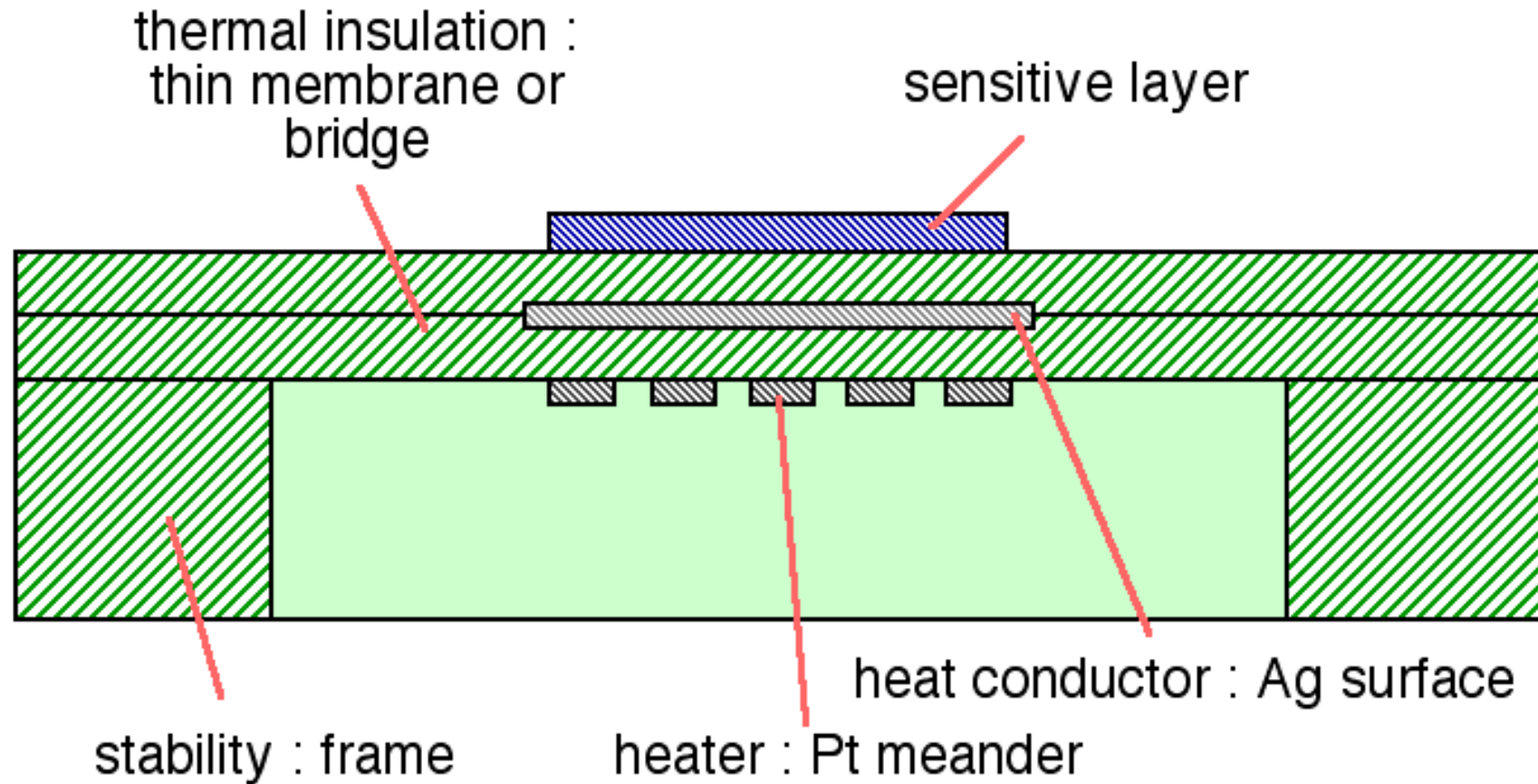
⇒ **LTCC outstanding for:**

- Thermal sensors
- Force & pressure sensors for small ranges

# Heated gas sensor



# Heated gas sensor - structure





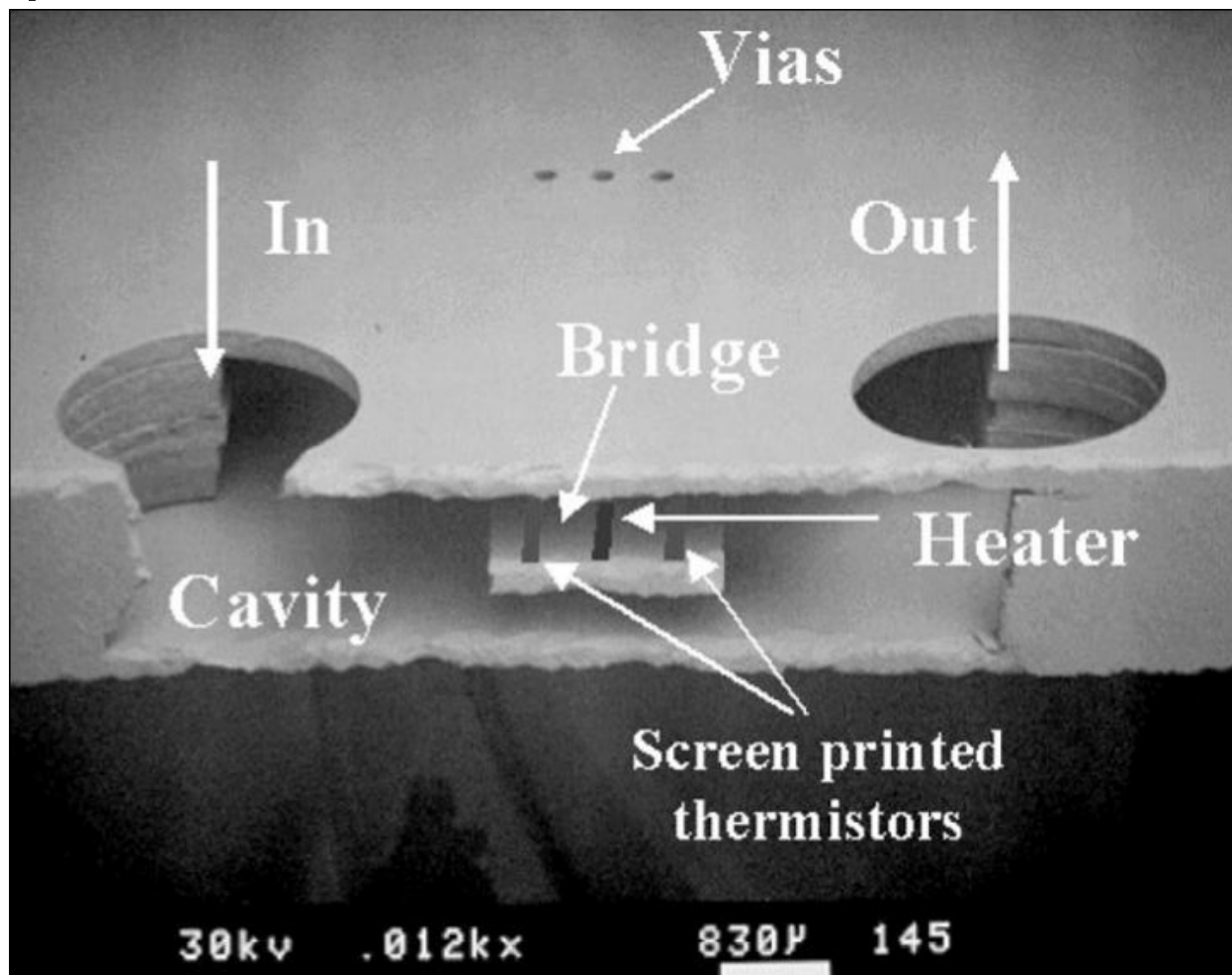
# Heated gas sensor - conduction

LTCC Conductivity	3 W/m/K
Ag conductivity	430 W/m/K
LTCC sheet conductance @ 100 $\mu\text{m}$	0.3 mW/K
Ag sheet conductance @ 10 $\mu\text{m}$	4.3 mW/K
LTCC conductive loss @ 400°C, 3:1	40 mW

- LTCC allows creation of “hot spots”
- Chemical devices
- Sensors for gas, flow, etc.

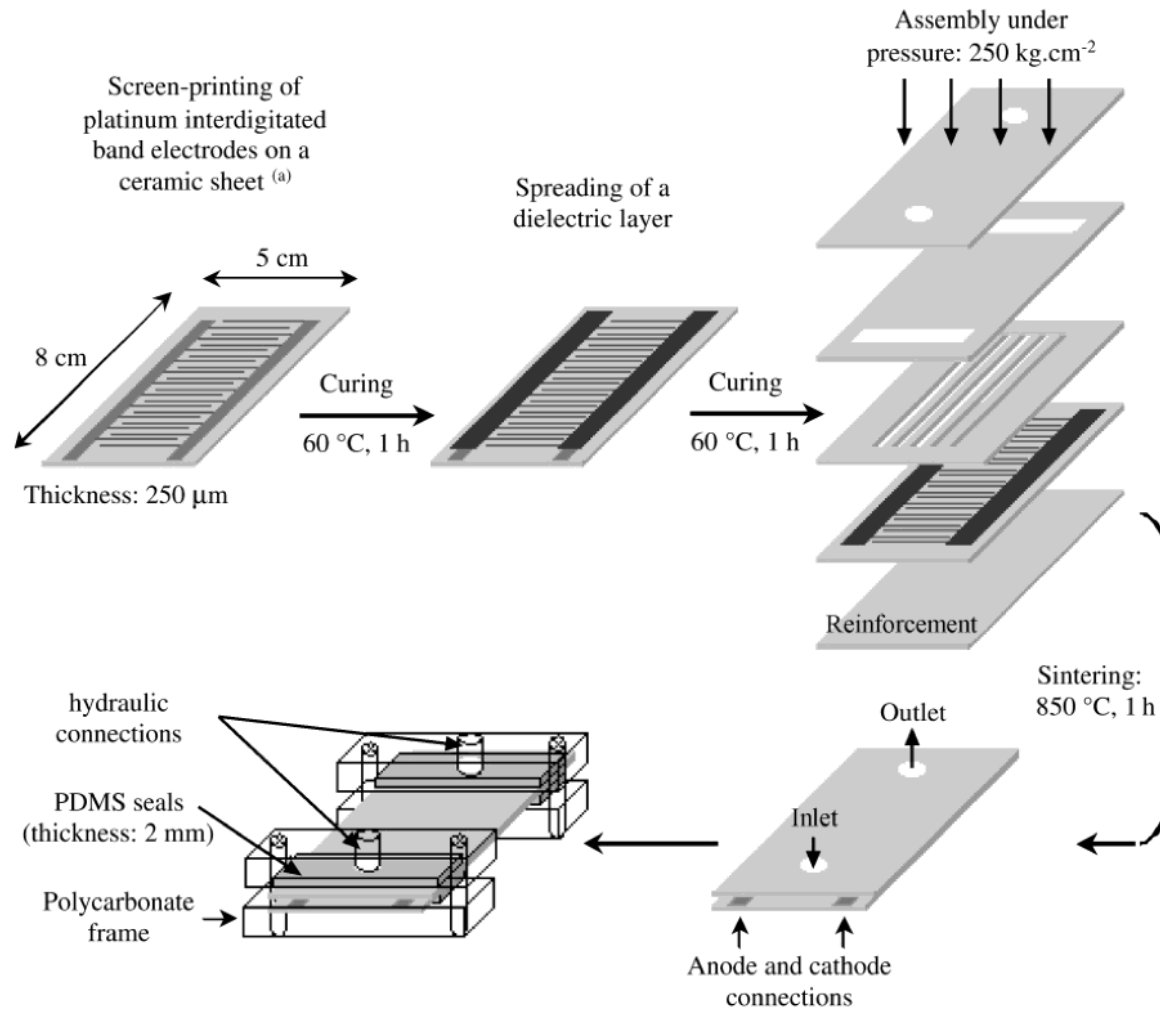


# Anemometric flow sensor



Gongora-  
Rubio et al.,  
2001

# Electrochemical microreactor



Mengeaud  
et al., 2001



# Conclusions

- Proven base material with wide application range - automotive & mobile communications
- Very good thermal & chemical stability
- Easy prototyping and fabrication of 3-D fluidic & electric circuits
- Functionalisation by appropriate films
- Integration of several functions into one device possible - “Lego” design
- Rapidly growing “cookbook”...